

This website uses cookies to improve the user's experience during working with our network and to provide users with dedicated services and functions. By further use you agree with that.OKDetails

Address	ANNEALSYS Bâtiment T2, PIT de la Pompignane Rue de la Vieille Poste 34055 Montpellier Cedex 1
---------	---

Country	France
---------	--------

PRODUCTS OR MACHINERY

AnnealSys designs and manufactures systems for:

- Rapid Thermal Processing (RTP)
- Rapid Thermal Chemical Vapor Deposition (RTCVD)
- Low Pressure Chemical Vapor Deposition (LPCVD)
- Metal Organic Chemical Vapor Deposition (MOCVD)

Applications are Research and Development, Quality Control, niche Production applications in the fields of Silicon and Compound Semiconductors, MEMS, Solar Cells, Glass ...

Annealsys offers service in rapid thermal annealing process from small pieces of wafers up to 6-inch diameter.

Annealsys has additional activities in service and refurbishing of Jipelec RTP systems

Company Profile of **ANNEALSYS**

A service of glasssglobal.com, an affiliate of glasssglobal group.

The address material you printed out is copyright and belongs to the Company or to its third party Marketing Agency, and all rights are reserved. Any User who accesses such material may do so only for its own personal use, and the use of such material is at the sole risk of the User. Redistribution or other commercial exploitation of such address material is expressly prohibited. Where such address material is provided by a third party, each User agrees to observe and be bound by the specific terms of use applying to such news material. Glass Global does not represent or endorse the accuracy or reliability of any of the info contained in any address or external websites referred to in this printout.www.glasssglobal.com - The International Portal to the Glass Industry - OGIS GmbH